(i) Touch-up of scratched surfaces or damaged maskant; and
(ii) Touch-up of trimmed edges.
(d) Controlled maskants—control system requirements. Each control system shall reduce the operation's organic HAP and VOC emissions to the atmosphere by 81% or greater, taking into account capture and destruction or removal efficiencies, as determined using the procedures in §63.750(g) when a carbon adsorber is used and in §63.750(h) when a control device other than a carbon adsorber is used.
(e) Compliance methods. Compliance with the organic HAP and VOC content limits specified in paragraphs (c)(1) and (c)(2) of this section may be accomplished by using the methods specified in paragraphs (e)(1) and (e)(2) of this section either by themselves or in conjunction with one another.
(1) Use chemical milling maskants with HAP and VOC content levels equal to or less than the limits specified in paragraphs (c)(1) and (c)(2) of this section.
(2) Use the averaging provisions described in §63.743(d).
§ 63.748 Standards: Handling and storage of waste.
Except as provided in §63.741(e), the owner or operator of each facility subject to this subpart that produces a waste that contains HAP shall conduct the handling and transfer of the waste to or from containers, tanks, vats, vessels, and piping systems in such a manner that minimizes spills.
§ 63.749 Compliance dates and determinations.
(a) Compliance dates. (1) Each owner or operator of an existing affected source subject to this subpart shall comply with the requirements of this subpart by September 1, 1998, except as specified in paragraph (a)(2) of this section. Owners or operators of new affected sources subject to this subpart shall comply with the compliance dates specified in §63.6(b) and (c).
(2) Owners or operators of existing primer or topcoat application operations and depainting operations who construct or reconstruct a spray booth or hangar must comply with the new source requirements for inorganic HAP specified in §§63.745(g)(2)(ii) and 63.746(b)(4) for that new spray booth or hangar upon startup. Such sources must still comply with all other existing source requirements by September 1, 1998.
(b) General. Each facility subject to this subpart shall be considered in noncompliance if the owner or operator fails to submit a startup, shutdown, and malfunction plan as required by §63.743(b) or uses a control device other than one specified in this subpart that has not been approved by the Administrator, as required by §63.743(c).
(c) Cleaning operations. Each cleaning operation subject to this subpart shall be considered in noncompliance if the owner or operator fails to institute and carry out the housekeeping measures required under §63.744(a). Incidental emissions resulting from the activation of pressure release vents and valves on enclosed cleaning systems are exempt from this paragraph.
(1) Hand-wipe cleaning. An affected hand-wipe cleaning operation shall be considered in compliance when all hand-wipe cleaning solvents, excluding those used for hand cleaning of spray gun equipment under §63.744(c)(3), meet either the composition requirements specified in §63.744(b)(1) or the vapor pressure requirement specified in §63.744(b)(2).
(2) Spray gun cleaning. An affected spray gun cleaning operation shall be considered in compliance when each of the following conditions is met:
   (i) One of the four techniques specified in §63.744(c)(1) through (c)(4) is used;
   (ii) The technique selected is operated according to the procedures specified in §63.744(c)(1) through (c)(4) as appropriate; and
   (iii) If an enclosed system is used, monthly visual inspections are conducted and any leak detected is repaired within 15 days after detection. If the leak is not repaired by the 15th day after detection, the solvent shall be removed and the enclosed cleaner shall